

**IN THE UNITED STATES PATENT AND TRADEMARK OFFICE**Applicant: Yan, *et al.*

Docket No.: 2003 P 51686 US

Serial No.: 10/615,630

Art Unit: 2825

Filed: July 9, 2003

Examiner: Calvin Lee

For: Method of Forming Shallow Trench Isolation Using Deep Trench Isolation

RECEIVED  
CENTRAL FAX CENTER  
SEP 13 2004Mail Stop Amendment  
Commissioner for Patents  
P.O. Box 1450  
Alexandria, VA 22313-1450**AMENDMENT**

Dear Sir:

The following amendments and remarks are presented in response to the Examiner's  
Office Action mailed June 18, 2004. Please amend the above-referenced application as follows.